

Journal of Organometallic Chemistry 532 (1997) 79-82



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> > Received 26 June 1996; revised 11 September 1996

Abstract

o-Bis(dimethylsilyl)benzene (1) reacts with cyclopentadienylbis(ethylene)cobalt at room temperature. This reaction results is overall double Si-H activation, generating the distlacobaltacycle complex Cp(C₂H₄)Co(o-Me₂SiC₆H₄SiMe₂) (3). Complex 3 was characterized by X-ray diffraction. 1,2,4,5-Tetrakis(dimethylsilyl)benzene reacts with CpCo(C₂H₄)₂ to give 4,12,6,10-benzo-1,1,3,3,7,7,8,9,9-nonamethyl-1,3-disilacobaltacycle-7,8,6,9-pentamethyl-6,-ene (4). Complex 4 was characterized by X-ray diffraction and found to contain a 6,10-benzo-7,7,8,9,9-pentamethyl-7,9-disilacyclopent-6-ene (4).

Keywords: Cobalt; Disilacobaltacycle; Double silylation; Silicon

1. Introduction

Silyl transition metal complexes now constitute a well recognized class of reagents and intermediates in organic synthesis [1]. Rhodium [2], nickel [3], palladium [4] and platinum complexes [5,6] catalyze various synthetic organic reactions such as hydrosilation and dehydrogenative double silvlation. Of particular importance among transition metal complex catalyzed syntheses of silicon compounds is the double silvlation of unsaturated hydrocarbons with silanes. In the double silvlation process, the cyclic bis(silyl)metal moiety is thought to play an important role as a reactive intermediate [3-6]. However, a few studies have been directed towards the preparation of complexes in which two silicon atoms are joined to a metal in a cyclic structure [7]. We report herein the first example of monomeric disilacobaltacycle complexes that contain bis(silyl)groups and ethylene in a proximal position.

2. Experimental, results and discussion

Treatment of $CpCo(C_2H_4)_2$ [11] with an equimolar amount of 1 in toluene at room temperature gave the disilacobaltacycle complex 3 in 32% yield, which was obtained as a yellow crystalline solid. In the solid state 3 seems to be indefinitely stable when kept under N₂. In common organic solvents, however, the complex is slowly decomposed. Analytical and spectral data are in accord with the proposed formulation.

 $[C_pCot(Me_2SiC_6H_6SiMe_2)(C_2H_4)]$ 3 was prepared as follows. Toluene (40 ml) was added to a flask containing CpCo(C_2H_4)_2 (1.02 g, 5.67 mmol) and 1 (1.10 g, 5.67 mmol) under ethylene atmosphere. The mixture was stirred for four days at room temperature and all volatiles were removed in vacuo. The reaction mixture was subjected to a chromatographic work-up (silica gel, hexane) under nitrogen. X-ray suitable crystals were obtained from hexane at $-15^{\circ}C$.

Selected spectroscopic data for 3. ¹H NMR (300 MHz, C_0D_6 , at 25°C): δ 7.67 (2H, *Ph*), 7.40 (2H, *Ph*), 4.532 (5H, C_3H_3), 1.82 (4H, C_2H_3), 1.11 (6H, Si-*Me*), 0.77 (6H, Si-*Me*). ¹³C NMR (C_0D_6): δ 152.26, 151.86, 130.13, 86.13, 36.65, 8.37, 5.32. ³⁹Si NMR

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 $(C_6 D_6)$: δ 50.52. MS m/z 344 (28%, M⁺), 316 (92%, M⁺ C₂H₄). Satisfactory analytical data were obtained.

The ¹H NMR spectrum of 3 shows two sets of peaks due to the hydrogens of the Si-Me groups. The peaks can be assigned to the two sets of methyl groups situated on opposite sides of the Si(1)-Si(2) vector.



In addition, the ¹H NMR spectrum of 3 included two sets of peaks, arising from the non-equivalent carbons of coordinated ethylene at $\delta 2.74$ and 0.90 at -15° C. Upon warming the solution at 25 °C, these two peaks coalesced to one broad resonance at 1.82 ppm. This result is consistent with the presence of a coordinated ethylene molecule, and is similar to that reported for other transition metal complexes involving a coordinated ethylene [12]. The ¹³C NMR spectrum is also consistent with the presence of the two sets of methyl groups situated on opposite sides and a symmetrical ethylene fragment. Its formulation was confirmed by X-ray diffraction.

Crystral data for 3. $C_{17}H_{25}Si_2Co$, M = 344.49, space group $P2_{\perp}/c$ (No. 14), a = 8.52S(4), b = 15.003(5), c = 13.490(3)Å, $\beta = 93.60(3)^\circ$, V = 1722(1)Å³, $D_{culc} = 1.329$ gcm⁻³, Z = 4. Of the 3358 unique reflections collected ($48.56^\circ < 2\theta < 49.91^\circ$) with Mo K α ($\lambda =$ 0.71069Å), the 2388 with $I > 3.00\sigma(I)$ were used in the final least-squares refinement to yield R = 0.032and $R_w = 0.048$. The non-hydrogen atoms were refined anisotropically. As shown in the ORTEP diagram (Fig. 1), the complex has a square-pyramidal geometry about the cobalt with two silyl groups and ethylene forming the base of a square pyramid with the $C_{1}H_{5}$ tigand in the capping position. The olefin and Si(1)–Co–Si(2) vcctors are nearly parailel. The Co–Si bond distances of



Fig. 1. Molecular structure of 3. Selected bond distances (Å) and angles (*): Co-5K(1) 2.290(1), Co-5K(2) 2.293(1), Co-C(16) 2.035(3), Co-C(17) 2.035(3), Si-C(1) 1.893(3), Si(2)-C(16) 1.897(3), C(16)-C(17) 1.399(5); Si(1)-Co-Si(2) 81.33(5), Co-Si(1)-C(1) 105.3(1), C(16)-Co-C(17) 40.2(1), Co-C(16)-C(17) 69.9(2).

12.290(1) and 2.293(1) Å are shorter than those of the platinum complex with 1,2-disilylbenzene [12.428(2) and 2.383(1)Å] [8], ReH₅(disil)(PPh₃)₂ [2.495(2) and 2.489(3)Å] [9], and Ria[SiMe_2CH_2SH2](H)-(PMe_3), [2.832(2) and 2.839(2)Å] [10]. The C(16)-C(17) bond distance [1.399(5)Å] of ethylene in 3 is directly comparable with that found in $Co(C_0H_0)(C_2H_4)$ -(PMe_3), [1.43(1)Å] [13] and (C_5Me_3)RA(C_2H_4)/PPh_3) [1.430(16)Å] [14]. The Co-C(16)/C(17) distance [2.035Å] falls well within the range commonly observed for ethylene cobalt complexes.

Complex 4 can readily be prepared by the reach \rightarrow of 2 with two molar amounts of CpCO(C₃H₄)₂ in toluene in 12% yield, and its structure can be ascertained by NMR spectroscopy.

Selected spectroscopic data for 4. ¹H NMR (300 MHz, C_6D_6 , at 25 °C): δ 7.55 (2H, *Ph*), 4.90 (SH, C_5H_3), 1.93 (4H, C_2H_4), 1.52 (d, 3H, *CH*,), 1.26 (6H, Si-*Me*), 1.15 (6H, Si-*Me*), 0.87 (6H, Si-*Me*), 0.66 (6H, Si-*Me*), 0.50 (q, 1H, *CH*). ¹³C NMR (C_6D_6): δ 154.28 (2C, aromatic Si-C), 131.42 (2C), 129.38 (2C), 88.22 (*Cp*), 37.92 (*CH*₂), 8.84 (CH*CH*₃), 8.46, 8.34, 5.52, 5.42 (Si-*CH*₃), -1.44 (*CHCH*₃). ²⁹Si NMR(C_6D_6): δ 47.82, 2.06. Satisfactory analytical data were obtained.

The observation of four Me singlets for the Si-Me in the ¹H NMR spectrum is in agreement with the existence of four non-equivalent CH_3 groups. The ¹³C NMR spectrum of 4 reveals four resonances at 8.46, 8.34, 5.52 and 5.42 ppm attributed to four non-equivalent CH_3 carbons, and two resonances at 8.84 and



Fig. 2. Molecular structure of 4. Selected bond distances (Å) and angles (*): Co(1)–Si(2) 2.304(3), Co(1)–Si(12) 2.283(3), Co(1)– C(22) 2.039(12), Co(1)–C(23) 2.307(13), Si(2)–C(3) 1.868(10), Si(12)–C(11) 1.8009(10), Si(6)–C(7) 1.993(28), Si(8)–C(7) 1.837(27); Si(2)–Co(1)–Si(12) 82.4(1), C(22)–Co(1)–C(23) 39.5(5), Si(6) C(7)–Si(8) (03.5(12).

-1.44 ppm due to MeC carbons. These data are in accord with the structure in 4, which has been unequivocally established by an X-ray study.

Crystral data for 4. $\operatorname{CoC}_{23}\operatorname{H}_{29}^2\operatorname{Si}_4$, space group P2, 2, 2, 1, a = 12.44206(6), b = 17.7380(8), c = 12.2910(5) Å, V = 2712.6(2) Å³, $D_{calc} = 1.496$ g cm⁻³, Z = 4. Of the 19418 reflections collected ($0.0^\circ < 2\theta < 48.7^\circ$) with Mo K α ($\lambda = 0.7107$ Å), a total of 2196 unique reflections with $I > 3.00\sigma(I)$ were used in the

final least-squares refinement to yield R = 0.0754 and $R_w = 0.0901$. The non-hydrogen atoms were refined anisotropically.

An ORTEP representation of the molecule of 4 is shown in Fig. 2, which also includes the atom labelling scheme. The molecular structure of 4 around Co shows this complex to be an isostructural species with that of 3. The Co-Si bond distances of 12.304(3) and 2.283(3) Å are similar to those of complex 3. The C(22)-C(23) bond distance of ethylene in 4 [1.376(19)Å] is comparable with that found in 3. An intriguing feature of the structure of 4 is that the complex contains two different moieties; the formation of disilacobaltacycle and the linkage of two silyl groups by a coordinated olefin. The structural configuration strongly suggests that the reaction of $CpCo(C_2H_1)_1$ with 2 proceeds via a double silvlation reaction. Tanaka et al. [6] recently reported the hydrogenative reaction of olefins with 1 in the presence of $(C_2H_4)Pt(PPb_3)_2$, proceeding to give the 4,5-benzo-1,1,3,3-tetramethyl-2alkyl-1,3-disilacyclopent-4-ene via 1,1-double silylation. They proposed the reaction mechanism as intramolecular insertion of a C=C bond into the Pt-H or Pt-Si bond. In this regard, the complex 4 provides an excellent model for the mechanistic study of the double silylation.

In an effort to obtain some information concerning the formation of 4, we have investigated the reaction of 3 in the presence or absence of a phenylacetylene. When a mixture of phenylacetylene and 3 was heated at 70 °C for 6 h, 1,1- and 1,2-double silylation occurred to form a mixture of 5 and 6 in an approximate 76:24 ratio in 92% yield, together with 1,3,5-triphenylbenzene. However, when the complex 3 was heated at 70 °C in the absence of a phenylacetylene, an intractable product was obtained. The structures of 5 and 6 have been determined from spectral data and confirmed by comparison with authentic compounds prepared by another route.



Selected spectroscopic data for **5**. ¹H NMR (300 MHz, CDCl₃): δ 7.48 (m, 2H, *Ph*), 7.28 (m, 2H, *Ph*). 1.26 (d, 3H, *CH*₃, *J* = 6.9 Hz), 0.57 (6H, Si-*Me*), 0.41 (q, 1H, *CH*, *J* = 6.9 Hz), 0.38 (6H, Si-*Me*), 1³C(¹H) NMR (CDCl₃): δ 147.42 (2*C*, aromatic, Si-C), 131.36 (2*C*), 130.94 (2*C*), 8.74 (*CH*₃), 3.08 (*CH*), 0.82 (2*C*, Si *Me*), -0.64 (2*C*, Si *Me*). MS *m*/*z* 220 (M⁺). Satisfactory analytical data were obtained.

A plausible mechanism for the formation of 5 and 6 is shown in Scheme 1. Compound 3 would involve the insertion of a coordinated ethylene into a cobalt-silicon bond, facilitated by the close proximity of these two ligands in the same plane. The formation of a sevenmembered intermediate 7 then allows rearrangement of ethylene to give 3,4-benzo-2,2,5,5,6-pentamethyl-1cobalta-2,5-disilacyclohex-3-ene 9 via an intermediate 8. The liberation of a CpCo fragment from intermediates 7 and 9 is concomitant with the linkage of siliconcarbon bonds, leading to the complexes 6 and 5 respectively. The role of a phenylacetylene would be to promote the insertion of a coordinated ethylene into a cobalt-silicon bond. However, we must await further investigations to elucidate a detailed reaction mechaniem

In summary, two novel disilacobaltacycle complexes **3** and **4** can be prepared by the reaction of $CpCO(C_2H_2)_2$ with *o*-bis(dimethylsilyl)benzene and 1,2,4,5tetrakis(dimethylsilyl)benzene respectively. The complexes **3** and **4** provide not only model complexes of the mechanistic rationale of known double silylation, but also a clue to developing unknown catalytic reactions starting from olefins and disilanes.

Acknowledgements

We gratefully acknowledge generous financial support from the KOSEF (92-2500-01-01-3). We thank Professor L.G. Sneddon at the University of Pennsylvania for crystallographic work. We also thank Dr. M. Ishikawa for helpful discussions.

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